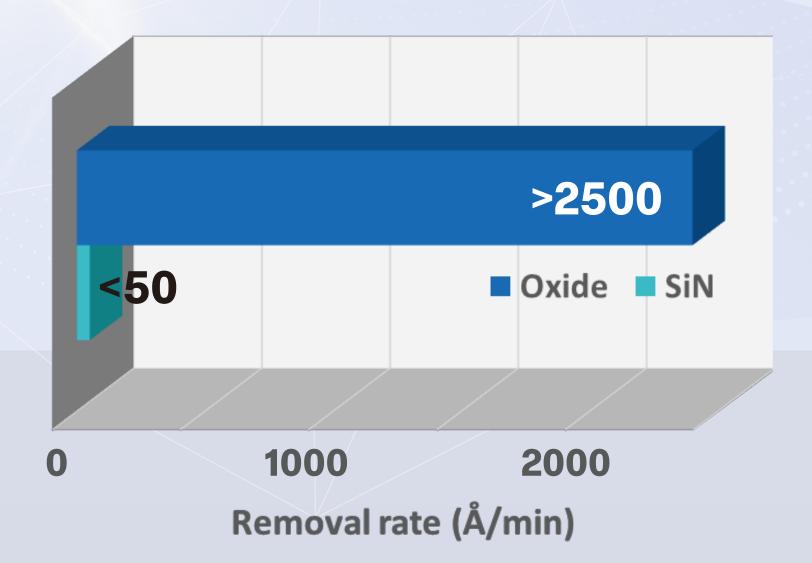
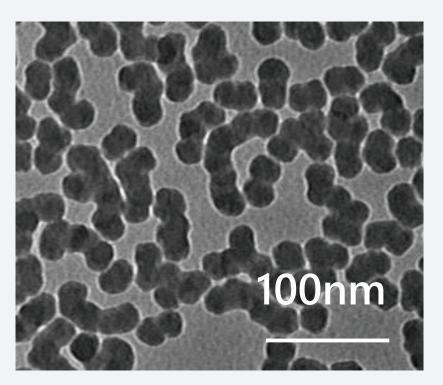
JSR CMP Slurry

Oxide Slurry

High oxide RR with highly associated silica abrasive



High degree of association abrasive



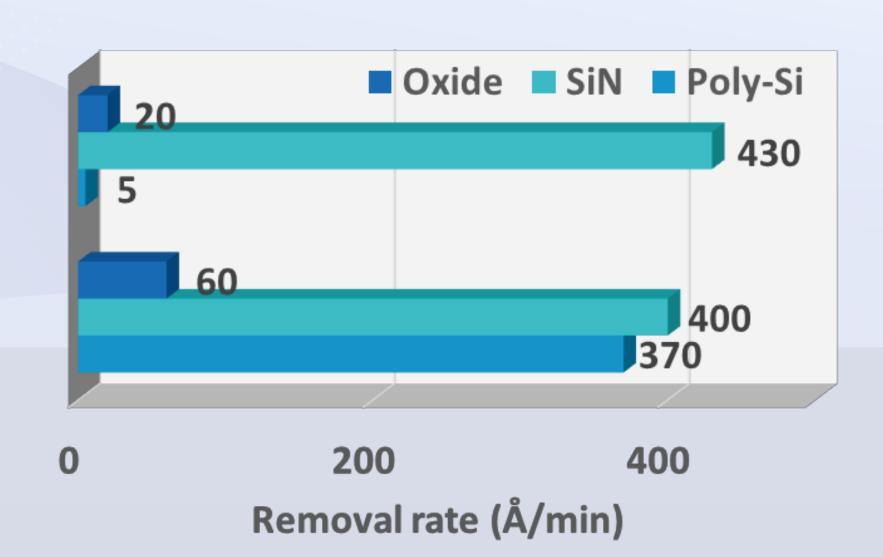
TEM Image

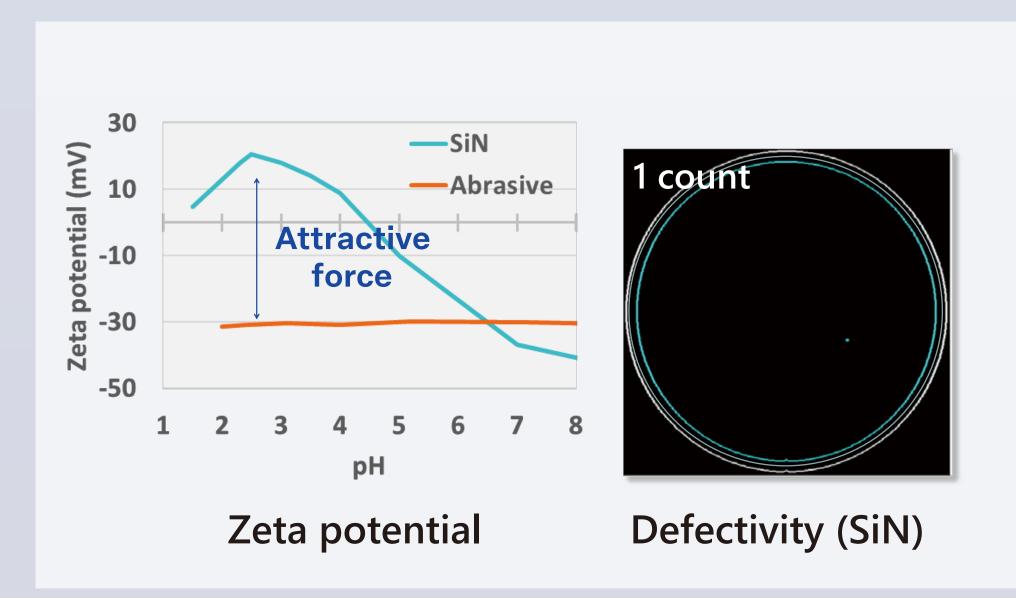


Defectivity (Oxide)

SiN Slurry

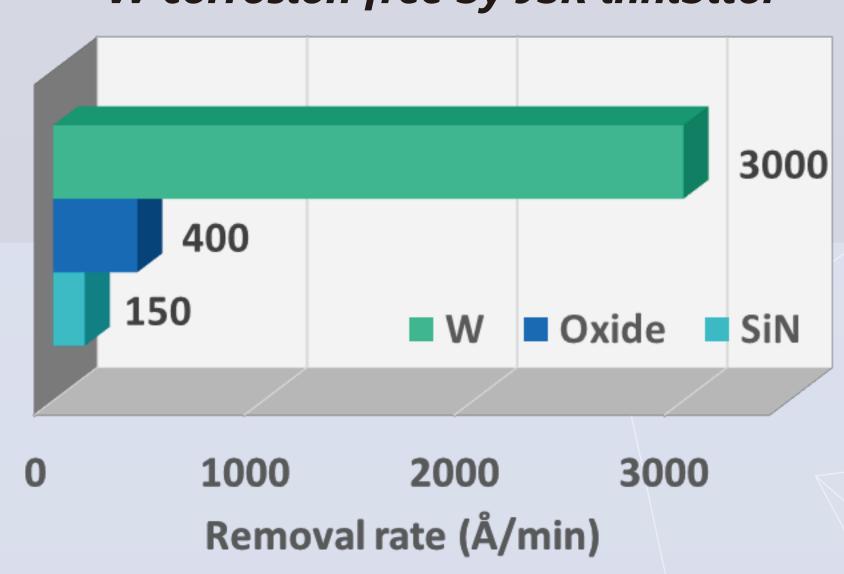
High SiN RR by Zeta potential control Tunable Poly-Si RR by additive selection

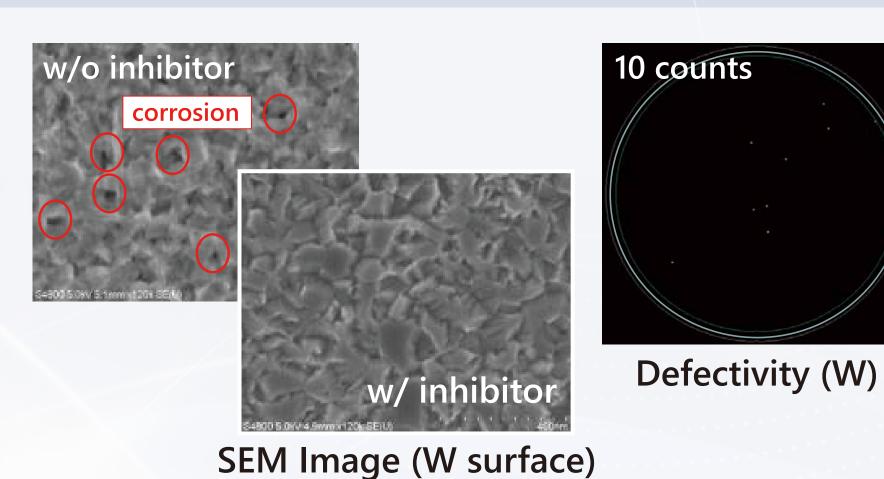




W Bulk Slurry

High W RR by catalyst system W corrosion free by JSR inhibitor





W Buff Slurry

Tunable selectivity to create well-controlled surface

